

Application Guideline for 2014 Osaka Invitational Program for Short-Term Overseas Trainees in Architecture and Arts

Osaka Invitational Program for Short-Term Overseas Trainees in Architecture and Arts is now accepting applications. This project is funded by Mr. Tadao Ando, a renowned architect from Osaka, and the companies who support the objectives of this program: to invite students and young professionals in the field of architecture and arts from countries in Asia to foster a deeper understanding of Japanese culture as well as to contribute to the developments of architecture and arts in their home countries.

1 Coordinator and host companies:

General construction companies in Osaka, and Osaka Foundation of International Exchange (OFIX)

2 Training period: September 25, 2014 to October 24, 2014 (30 days) (tentative)

3 Activities:

- (1) Practical training sessions and visits to construction sites of general construction companies in Osaka.
- (2) Group discussions with young professional architects as well as students in architecture and arts.
- (3) Excursions to visit buildings designed by Tadao Ando and historically significant sites in the Kansai area.
- (4) Homestay Program with OFIX volunteer families.
- (5) Participation in international understanding education event (English Project).

4 Program language : English

5 Expenses:

Expenses for the participants' accommodations, living expenses, basic travel insurance, and a round-trip economy class air ticket are provided by OFIX.

6 Number of trainees: 8 from Asian countries and regions

7 Qualifications

i) Must be either of the following:

- (1) Currently enrolled in or a graduate of a graduate school program

- (Masters/PhD) majoring in architecture or a related field. Or
- (2) Holding a Bachelor's degree and currently working as an architect or in a related field
- ii) Must have a high level of English proficiency to discuss and write topics in architecture. (TOEIC score of 700 or equivalent)
- iii) Applicant must not be over 35 years old at the time of application.
- iv) Must be of an Asian nationality and currently residing in Asia.

8 Assessment method by the selection committee:

Participants will be selected by the selection committee and secretariat based on the application documents (telephone interview may be conducted if necessary)

*Primary Screening: mid June 2014 *Secondary Screening: late June 2014

Final results will be released in late June 2014

9. Required documents

- i) OFIX Official Application Form for Osaka Invitational Program for Short-Term Overseas Trainees in Architecture and Arts (Design Work, Statement of Purpose and Essay included)
- ii) Curriculum vitae(CV) (English)
- iii) Original certificate of graduation of highest educational attainment.
(current graduate students do not need to submit)
- iv) Original certificate of enrollment (only for current graduate students)
- v) Original certificate of employment (only for those currently employed)
- vi) Letter of recommendation from any one of the following institutions who can properly assess the performance of the applicant
- (1) Institutions or organizations related to architecture field
(Representative of institution or superior of the applicant, etc)
- (2) University or other higher educational institutions
(Former or present professor, etc)
- (3) Public institutions or organizations recognized by OFIX
- vii) Copy of English proficiency certification (within the past two years)
official score of English proficiency test
(i.e TOEIC,TOEFL,IELTS... *transcript of records of English classes published by universities etc is not acceptable.)
- Note: Please inquire at OFIX if you have questions about English proficiency certification

10. Important notes

(1) Applications must be sent to OFIX by airmail.

*****Applications submitted by email will NOT be accepted**

(2) Incomplete applications or applications received after the deadline will NOT be considered.

<Application deadline> : **May 19 (Monday), 2014**

(must be received at OFIX on or before)

<Submission/ Inquiry>

Osaka Foundation of International Exchange (OFIX)

5F My Dome Osaka 2-5 Honmachibashi, Chuo-ku, Osaka-city, Osaka, 540-0029, Japan

Phone: (+81) 6-6966-2400 Fax: (+81) 6-6966-2401

E-mail: Andoprogram@ofix.or.jp

OFIX HP: <http://www.ofix.or.jp/>

Program Detail: <http://www.ofix.or.jp/english/aprogram/overview.html>

Application: <http://www.ofix.or.jp/aprogram/pdfs/2014application.pdf>